

Palladium-catalyzed Direct C–H Bond Arylation of Simple Arenes with Aryltrimethylsilanes

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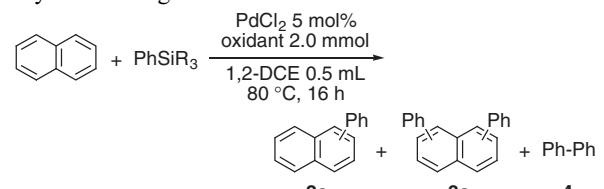
Direct C–H bond arylation of arenes with aryltrimethylsilanes catalyzed by PdCl_2 in the presence of CuCl_2 as an oxidant has been developed. In addition to the role as the oxidant, CuCl_2 is found to be necessary for the selective cross-coupling reaction.

Biaryl structures are very important units in fine chemicals, such as organic electronic materials, pharmaceuticals, and agrochemicals. The cross-coupling reactions of various arylmetal reagents with aryl halides catalyzed by nickel or palladium have been widely utilized for the biaryl synthesis.^{1,2} In recent years, transition-metal-catalyzed direct C–H bond arylation has attracted significant attention as an efficient and useful method for biaryl synthesis.³ There have been many studies of direct arylation of highly electron-rich heteroaromatic compounds⁴ and arenes involving nitrogen- or oxygen-based directing groups.⁵ In contrast, the direct arylation of simple aromatic hydrocarbons, such as naphthalene and phenanthrene, has been less studied.⁶

In the previous work, we reported the direct C–H bond arylation of simple arenes with aryltin trichlorides in the presence of a catalytic amount of $\text{Pd}(\text{II})$ salt and stoichiometric amount of CuCl_2 .^{6b} The reaction mechanism is proposed to involve a highly electrophilic arylpalladium intermediate which would easily react with arenes via electrophilic substitution. Since aryltin trichlorides are difficult to handle and highly toxic, we set out to develop more practical direct C–H bond arylation using arylsilicon compounds, which are easy to handle, show low toxicity, and are easily available, as alternative arylmetal reagents. Herein, we report that aryltrimethylsilanes successfully reacted with simple arenes to give the corresponding cross-coupling products in the presence of palladium catalyst and CuCl_2 as the oxidant and activator of the catalyst. To the best of our knowledge, there has been no example of the direct C–H bond arylation using aryltrialkylsilanes.⁷

At first, the reactions of naphthalene (0.5 mmol) with phenylsilicon reagents (1.0 mmol) were examined using PdCl_2 (5 mol %, 0.025 mmol) and oxidants (2.0 mmol) in 1,2-dichloroethane (1,2-DCE, 0.5 mL) at 80 °C for 16 h (Table 1). After the screening, desired products **2a** and **3a** were obtained in moderate yields by the use of PhSiMe_3 (**1a**) and CuCl_2 (Entry 1). When the amount of **1a** was increased to 2.0 mmol, the total yield of the cross-coupling products was increased to 59% (Entry 2). In the case of phenylsilanes with bulky alkyl groups on the silicon, the yields of the coupling products were decreased considerably (Entries 3 and 4). The use of phenylalkoxysilanes, which are known to be good reagents for coupling reactions,⁸ decreased the yields of **2a** and **3a** (Entries 5–7). The reaction of PhSiCl_3

Table 1. Direct C–H bond arylation of naphthalene with phenylsilicon reagents^a



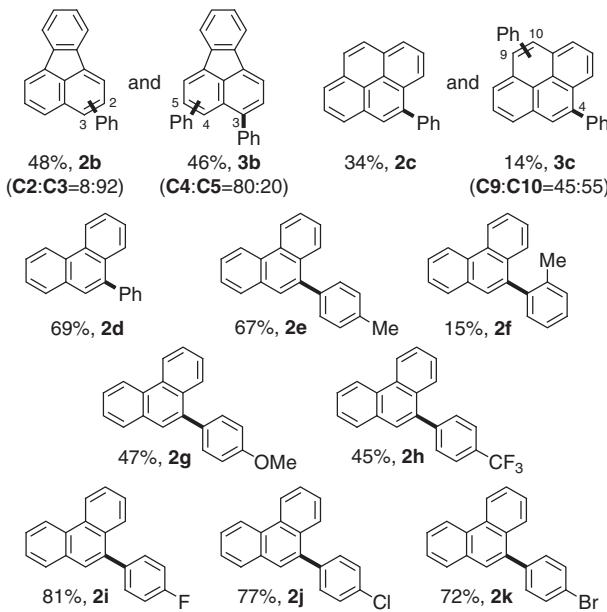
Entry	PhSiR ₃	Oxidant	Yield/% ^b			
			2a ^c	(α : β)	3a ^c	4 ^d
1	1a	CuCl_2	38	(87:13)	7	0
2 ^e	1a	CuCl_2	35	(89:11)	24	12
3	PhSiEt_3	CuCl_2	30	(83:17)	0	3
4	PhSi-i-Pr_3	CuCl_2	0		0	0
5	$\text{PhSiMe}_2(\text{OEt})$	CuCl_2	23	(83:17)	0	31
6	$\text{PhSiMe}(\text{OMe})_2$	CuCl_2	16	(81:19)	0	1
7	$\text{PhSi}(\text{OMe})_3$	CuCl_2	4	(100:0)	0	0
8	PhSiCl_3	CuCl_2	0		0	0
9	1a	$\text{Cu}(\text{OAc})_2$	2	(79:21)	0	1
10	1a	CuSO_4	6	(94:6)	0	0
11	1a	CuF_2	4	(88:12)	0	0
12	1a	CuBr_2	0		0	1
13	1a	none	0		0	0
14 ^f	1a	CuCl_2	0		0	0

^aReaction conditions: Naphthalene (0.5 mmol), phenylsilicon reagent (1.0 mmol), PdCl_2 (0.025 mmol), and oxidant (2.0 mmol) in 1,2-DCE (0.5 mL) at 80 °C for 16 h. ^bDetermined by GC.

^cBased on naphthalene. ^dBased on phenylsilicon reagent.

^e2.0 mmol of PhSiMe_3 was used. ^fReaction without PdCl_2 .

did not proceed in the present catalytic system (Entry 8). Among the several oxidants examined, CuCl_2 showed the best result (Entries 9–12). In addition, the reaction without the oxidant did not proceed at all (Entry 13). The use of other palladium catalysts, such as $\text{Pd}(\text{OAc})_2$, $[\text{PdCl}_2(\text{MeCN})_2]$, $[\text{PdCl}_2(\text{PhCN})_2]$, $[\text{PdCl}_2(\text{cod})]$, and $[\text{Pd}_2(\text{dba})_3]$, decreased the yield of the cross-coupling product (4–26% yield) and increased the yield of biphenyl (**4**) (30–81% yield). Palladium complexes with electron-donating ligands, such as $[\text{PdCl}_2(\text{PPh}_3)_2]$ and $[\text{PdCl}_2(\text{bpy})]$, did not give any coupling products. As a control experiment, the reaction without palladium catalyst did not proceed (Entry 14). The predominant formation of the α -coupling product strongly suggests that the reaction pathway involves an electrophilic substitution on the naphthalene ring.



Scheme 1. Direct C–H bond arylation of several arenes with aryltrimethylsilanes.

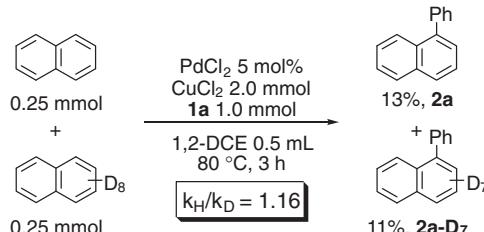
Scheme 1 shows the results of the direct arylation of several arenes with various aryltrimethylsilanes under the optimized reaction conditions (Table 1, Entry 2). The reaction of fluoranthene with **1a** afforded mono- and diphenylated products in 48% (**2b**, C₂:C₃ = 8:92) and 46% yield (**3b**, C₄:C₅ = 80:20), respectively. Phenylation of pyrene gave 4-phenylpyrene (**2c**) in 34% yield and diphenylated pyrene **3c** in 14% yield (C₉:C₁₀ = 45:55). The reactions of phenanthrene with various aryltrimethylsilanes having both electron-donating and -withdrawing groups at their 4-positions gave the corresponding 9-arylphenanthrenes **2d**, **2e**, and **2g**–**2k** in 45 to 81% yields. A clear correlation between the electronic properties of the aryltrimethylsilanes and the product yields was not observed. It is noted that 4-halogenated phenyltrimethylsilanes gave halogen-substituted products **2i**–**2k**, which can be used for further coupling reactions at the halogen substituents. The reaction using sterically hindered *o*-tolyltrimethylsilane gave the product **2f** in a low yield of 15%.¹³

To clarify the role of CuCl₂, effect of the amount of CuCl₂ was then examined in the reaction of naphthalene (0.5 mmol) with **1a** (1.0 mmol) using PdCl₂ (0.10 mmol) in 1,2-DCE (1.0 mL) at 80 °C (Table 2). The reactions were carried out for 3 h to form only monophenylated product **2a**. The reaction without CuCl₂ did not give any coupling products, because of insolubility of PdCl₂ (Entry 1). Thus, the use of soluble [PdCl₂(MeCN)₂] without CuCl₂ gave only biphenyl (**4**) as the homocoupling product of **1a** (Entry 2). The reaction using PdCl₂ with 1.0 mmol of CuCl₂ afforded the cross-coupling product **2a** together with almost the same amount of **4** (Entry 3). On the other hand, the use of [PdCl₂(MeCN)₂] with 1.0 mmol of CuCl₂ gave **4** predominantly (Entry 4). Addition of larger amounts of CuCl₂ to PdCl₂ catalyst then resulted in the preferential formation of **2a** (Entries 5 and 6). These results show that the amount of CuCl₂ affects the reaction selectivity between cross-coupling and homocoupling reactions. It is reasonable to

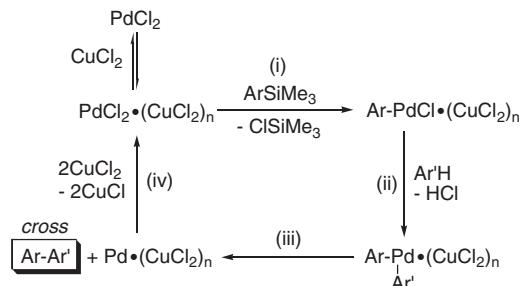
Table 2. Investigation of the effect of CuCl₂

Entry	CuCl ₂ , x/mmol	mmol by GC		2a:4
		2a	4	
1	0	0	0	—
2 ^a	0	0	0.071	0:1
3	1.0	0.044	0.040	1.1:1
4 ^a	1.0	0.015	0.40	1:27
5	2.0	0.049	0.005	10:1
6	3.0	0.074	0.003	25:1

^a[PdCl₂(MeCN)₂] (0.1 mmol) was used instead of PdCl₂.



Scheme 2. Kinetic isotope effect on the reaction of naphthalene with **1a**.



Scheme 3. A presumed reaction pathway.

suppose that this reaction selectivity is caused by the formation of polynuclear Pd–Cu clusters.^{9,10} It is also possible that CuCl₂ oxidizes a Pd(II) intermediate to a Pd(III) or Pd(IV) species.¹¹ Acetonitrile ligands on the palladium catalyst would prevent such interactions between palladium and copper.

Kinetic isotope effect was also investigated by the competitive reaction between naphthalene and naphthalene-D₈ with **1a** (Scheme 2). The k_H/k_D ratio was determined to be 1.16. This suggests that the C–H bond cleavage of naphthalene by a palladium intermediate proceeds via the electrophilic substitution mechanism.

A presumed reaction pathway is shown in Scheme 3. Electrophilic transmetalation of PdCl₂ with ArSiMe₃ at the *ipso*-Si position¹² generates an arylpalladium intermediate in the presence of CuCl₂ (i). Aromatic electrophilic substitution of Ar'–H with the arylpalladium intermediate occurs to form a diarylpalladium intermediate (ii). The exact structure of the arylpalladium intermediate has not yet been clear, the interaction with CuCl₂ would be crucial in this step. Reductive elimination

from the diarylpalladium species gives the cross-coupling products (iii). Finally, oxidation of palladium species by CuCl₂ regenerates PdCl₂ (iv).

In summary, palladium-catalyzed direct C–H bond arylation of simple arenes with aryltrimethylsilanes is described. In this reaction, CuCl₂ is essential to obtain the desired cross-coupling products in high selectivity. Further studies to expand the substrate scope and their applications, as well as the investigations for the reaction mechanism are now in progress.

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